

MSE-609

**21Intro Scanning electron microscopy techniques**

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<b>Cursus</b>	<b>Sem.</b>	<b>Type</b>
Materials Science and Engineering		Opt.

Language of teaching	English
Credits	1
Session	
Exam	Written
Workload	30h
<b>Hours</b>	<b>18</b>
Courses	15
Exercises	3
<b>Number of positions</b>	<b>16</b>

**Frequency**

Every 2 years

**Summary**

Modern Scanning Electron Microscopes, when combined with focused ion beams (Dual beam FIBs), provide a larger number of multimodal imaging and different analytical methods. The course format consists of introductory lectures, lectures on advanced techniques and practical work.

**Content**

The following subjects will be presented during the course:

- Basics of the scanning electron microscopy and focused ion beam instruments (construction principles, signals, interaction with the sample)
- Advanced imaging modes: STEM, low tension microscopy, high vacuum, ion channeling
- Advanced microstructure investigation with EBSD and transmission EBSD orientation mapping (EBSD strain and stress analyses with cross correlation technique)
- Chemical analyses with EDS, WDS and  $\text{ICP-XRF}$
- Chemical depth profile with FIB-TOF-SIMS
- Raman spectrometry for phase and strain/stress analyses

The techniques will be explored in small groups on real samples in front of SEMs

**Note**

This course is open to participants with a basic background in materials science, mechanical engineering, chemical engineering, micro-technology or physics.

**Keywords**

Scanning Electron Microscopy; microanalysis, multimodal imaging, analytical methods, chemical analysis